Valley lifetimes in monolayer WSe₂ from time-resolved Kerr-rotation measurements

Manfred Ersfeld¹

Frank Volmer¹, Lars Rathmann¹, Luca Kotewitz¹, Maximilian Heithoff¹, Mark Lohmann², Bowen Yang³, Kenji Watanabe⁴, Takashi Taniguchi⁴, Ludwig Bartels³, Jing Shi², Christoph Stampfer^{1,5} and Bernd Beschoten¹

¹2nd Institute of Physics and JARA-FIT, RWTH Aachen University, 52074 Aachen, Germany ²Department of Physics and Astronomy, University of California, Riverside, California 92521, USA ³Department of Chemistry and Materials Science Engineering Program, University of California, Riverside, California 92521, USA

⁴National Institute for Materials Science, 1-1 Namiki, Tsukuba, 305-0044, Japan ⁵Peter Grünberg Institute (PGI-9), Forschungszentrum Jülich, 52425 Jülich, Germany Manfred.Ersfeld@rwth-aachen.de

Two-dimensional transition metal dichalcogenides (TMDs) offer the possibility to address the electron's valley degree of freedom making them interesting for valley-based electronics, so-called valleytronics. We report on nanosecond long, gate-dependent valley lifetimes of free charge carriers in WSe₂, unambiguously identified by the combination of time-resolved Kerr rotation (TRKR), Photoluminescence (Fig. 1a) and electrical transport measurements. While the valley polarization increases, black data points in Fig. 1b for U_{BG} >0, when tuning the Fermi level into the conduction (Fig 1b) or valence band, there is a strong decrease of the respective valley lifetimes, black data points Fig. 1c, consistent with both electron-phonon and spin-orbit scattering. The longest lifetimes are seen for spinpolarized bound excitons in the band gap region, red data points in Fig. 1c. We explain our findings via two distinct, Fermi level-dependent scattering channels of optically excited, valley polarized bright trions either via dark or bound states. By electrostatic gating we demonstrate that WSe₂ can be tuned to be either an ideal host for long-lived localized spin states or allow for nanosecond valley lifetimes of free charge carriers (>10 ns) explaining the huge variation in previously reported lifetimes extracted from TRKR [1],[2],[3]

References

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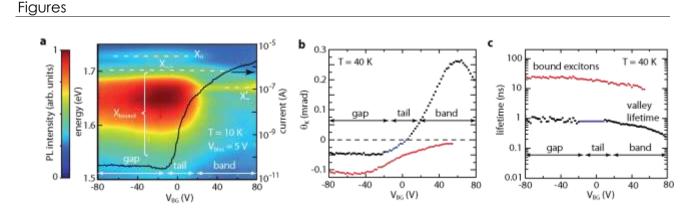


Figure 1: a) Gate-dependent photoluminescence and electrical transport measurements are used to determine the position of the Fermi level within the band structure of the TMD as a function of gate-voltage. b) Gate-dependent Kerr rotation amplitudes θ_{K} and c) lifetimes.

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